Docket No.: 005916 USA/FPS/MMCS/MC

PATENT/OFFICIAL OFF

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of

Young Joseph PAIK

Serial No. 09/998,384

Group Art Unit: 2812

Filed: November 30, 2001

: Examiner:

For:

FEEDFORWARD AND FEEDBACK CONTROL FOR CONDITIONING OF

CHEMICAL MECHANICAL POLISHING PAD

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This submission does not constitute a representation that a search has been made or that no better art exists and does not constitute an admission or representation that any of the listed documents is material or constitutes prior art. If it should be determined that any of the listed documents does not constitute prior art under the United States law, Applicants reserve the right

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Serial No. 09/998,384

to present to the Office the relevant facts and law regarding the appropriate status of such

document.

Applicant petitions for consideration of the enclosed documents by the Examiner. No

item of information contained in the information disclosure statement was cited in a

communication from a foreign patent office in a counterpart foreign application, and, to the

knowledge of the person signing this certification, after making reasonable inquiry, no item of

information contained in the information disclosure statement was known to any individual

designated in § 1.56(c) more than three months prior to the filing of the information disclosure

statement.

The petition fee of \$180.00 pursuant to 37 CFR § 1.17(p) is attached. The Commissioner

is authorized to charge any deficiency in any fees pursuant to 37 CFR § 1.17 associated with this

communication and to credit any excess payment to Deposit Account No. 08-0219.

Respectfully submitted,

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SHEET 1 OF 1

INFORMATION DISCLOSURE  O P CITATION IN AN  APPLICATION  (PTO-1449)				005916 USA	ATTY. DOCKET NO. 005916 USA/ FPS/MMCS/MC		SERIAL NO. 09/998,384	
AUG 0 8 2005 — (PTO-1449)					APPLICANT Young Joseph PAIK			
					FILING DATE November 30, 2001		GROUP 2812	
		U.	S. PATENT	OCUMENTS				
EXAMINER'S INITIALS	PATENT NO.	DATE		NAME	CLASS	SUBCLASS	FILING DATE	
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	OTHER	ART (Includ	ing Author,	Title, Date, Perti	nent Pages, Etc	.)		
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EXAMINER	DATE CONSIDERED							
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EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.